

update

	L #	Hits	Search Text	DBs	Time Stamp
✓ 1	L1	20	(ion adj blocking) with (SiN Si3N4 (silicon Si) adj nitride "Si.sub.3 N.sub.4" "Si.sub.3N.sub.4")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/12/20 12:41
✓ 2	L2	11	(soda adj lime adj glass) same (ion adj blocking SiN Si3N4 (silicon Si) adj nitride "Si.sub.3 N.sub.4" "Si.sub.3N.sub.4") same laser	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/12/20 12:05
✓ 3	L3	159	((ion adj blocking SiN Si3N4 (silicon Si) adj nitride "Si.sub.3 N.sub.4" "Si.sub.3N.sub.4") same (cyl indrical adj lens rectangular rectangle crosssection cross adj section beam adj spot) with laser) not (L1 or L2)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/12/20 12:18
✓ 4	L4	26	(ion adj blocking) with (SiO SiO SiO2 SiOx (silicon Si) adj (oxide dioxide) "SiO.sub.2" "SiO.sub.x") not (L1 or L2 or L3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/12/20 12:24
✓ 5	L5	277	((SiO SiO SiO2 SiOx (silicon Si) adj (oxide dioxide) "SiO.sub.2" "SiO.sub.x") same (cylindric al adj lens rectangular rectangle crosssection cross adj section beam adj spot) with laser) not (L1 or L2 or L3 or L4)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/12/20 12:26

08/169, 127
update - all remaining spec.

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	L #	Hits	Search Text	DBs	Time Stamp
✓ 6	L6	37	(soda adj lime adj glass) same (SiO SiO SiO2 SiOx (silicon Si) adj (oxide dioxide) "SiO.sub.2" "SiO.sub.x") same laser not (01 or L2 or L3 or L4 or L5)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/12/20 12:44
7	L7	3874	((427/554,555,556,581,582, 583,586,597,596) or (438/798,487)).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/12/20 12:35
8	L8	749	L7 and (laser beam irradiat\$7 scan\$4) same (crystal\$9 recrystal\$9) same (Si silicon polysilicon amorphoussilicon)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/12/20 12:46
9	L9	238755	L8 and (ion adj blocking) or (SiN Si3N4 (silicon Si) adj nitride "Si.sub.3 N.sub.4" "Si.sub.3N.sub.4")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/12/20 12:41
10	L10	351	L8 and ((ion adj blocking) or (SiN Si3N4 (silicon Si) adj nitride "Si.sub.3 N.sub.4" "Si.sub.3N.sub.4"))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/12/20 12:41
11	L11	6919	((ion adj blocking) or (SiO SiO SiO2 SiOx (silicon Si) adj (oxide dioxide) "SiO.sub.2" "SiO.sub.x") or (SiN Si3N4 (silicon Si) adj nitride "Si.sub.3 N.sub.4" "Si.sub.3N.sub.4")) same (laser beam irradiat\$7 scan\$4) same (crystal\$9 recrystal\$9) same (Si silicon polysilicon amorphoussilicon)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/12/20 12:43

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	L #	Hits	Search Text	DBs	Time Stamp
12	L12	6810	11 not (01 or L2 or L3 or L4 or L5 or 16)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/12/20 12:44
13	L13	255	L7 and L12	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/12/20 12:44
14	L14	34	L13 and (laser beam irradiat\$7 scan\$4) same (crystal\$9 recrystal\$9) same (Si silicon polysilicon amorphoussilicon) same (cyli ndrical adj lens rectangular rectangle crosssection cross adj section beam adj spot)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/12/20 12:48